

Lee Jones Accelerator Physics Group

Accelerator Science and Technology Centre STFC Daresbury Laboratory







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GaAs Photocathode R&D: Energy spread measurements and the nature of the activated p-GaAs(Cs,O) activation layer

- Overview of the TESS experimental system
- The nature of the p-GaAs(Cs,O) activation layer







Characterising photocathode sources: Transverse & Longitudinal Energy Distribution

- Brighter electron beams require reductions in the transverse and longitudinal energy distributions (TEDC & LEDC) of photocathode electron sources
- ASTeC have constructed a system to measure these
- Flexible experimental system designed and commissioned
 - Various light sources
 - Liquid nitrogen photocathode cooling loop
 - Degradation / lifetime studies
 - Connection to vacuum suitcase various cathodes
- System connected to our III-V Photocathode Prep. Facility

TESS – The Transverse Energy Spread Spectrometer



Increasing beam brightness: The intrinsic energy of NEA GaAs photocathodes



TESS - The Transverse Energy Spread Spectrometer



Increasing beam brightness: The intrinsic energy of NEA GaAs photocathodes

Retarding-field MCP Mu-metal magnetic Independent control of ٠ electron multiplier shield (cutaway) source & grid potentials Phosphor screen Cathode Ability to change the source-detector spacing Inclusion of leak valve to 'poison' the cathode Microchannel Plate (MCP) Laser beam path Cryogenic reservoir Cryogenic cooling pipes Phosphor screen Retarding grids

TESS - The Transverse Energy Spread Spectrometer





TEDC measurements at different accelerating voltages



$$d = 33 \text{ mm}$$
 $\lambda = 635 \text{ nm}$
 $T = 300 \text{ K}$



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Screen luminescence profiles

 $- U_{acc} = 40 V$ $- U_{acc} = 60 V$

 $- U_{acc} = 131 V$

 $--- U_{acc} = 82 V$

280 V Intensity, a.u. 5 mm

d = 33 mm $\lambda = 635 \text{ nm}$

T = 300 K

17.06.2013 p-GaAs(Cs,O) photocathode

1.2

1.0

0.8



TEDC measurements at different accelerating voltages



17.06.2013 p-GaAs(Cs,O) photocathode





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d = 33 mm $\lambda = 635 \text{ nm}$ T = 300 K

17.06.2013 p-GaAs(Cs,O) photocathode



TESS Commissioning: TEDC measurements with different wavelengths of light $\lambda = 635$ nm

 $\lambda = 532 \text{ nm}$





$$U_{\rm acc} = 230 \text{ V}$$



21.06.2013 p-GaAs(Cs,O) photocathode $d \approx 43$ mm T = 300 K





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Part 2:

GaAs Photocathode R&D: Energy spread measurements and the nature of the activated p-GaAs(Cs,O) activation layer

- Overview of the TESS experimental system
- The nature of the p-GaAs(Cs,O) activation layer







p-GaAs (Cs,O): Activation Layer Model

- The growth of GaAs photocathodes and photoelectron scattering phenomena in this material are well-understood
- The atomic and electronic properties of the p-GaAs(Cs,O)vacuum interface layer remain the focus of much research
- Several layer models proposed, with two likely candidates:
 - The *Dipole Layer* (DL) model, applicable to '*thin*' layers
 - The *Hetero Junction* (HJ) model, applicable to '*thick*' layers
- p-GaAs (Cs,O)-photocathodes with reasonably high *Q.E.* can be created with (Cs,O)-layers conforming to both models
- The domains of validity for these models have not been defined
- This has hindered our understanding of the interrelations between the *intrinsic characteristic parameters* of the (Cs,O)-layers and the *performance characteristics* of p-GaAs(Cs,O)-photocathodes



- Photocathode grown by MOCVD on a (001) GaAs substrate
- Activation under *near-equilibrium* conditions with illumination at 635 nm
- First Cs peak reached in 25 minutes. Deposition rate is 0.02 ML/min
- O_2 applied when photocurrent (J_{ph}) fallen to 98% of maximum value



• Activation interrupted periodically to measure the longitudinal energy spread (LEDC), $n_e^i(\varepsilon_{lon})$ at positions i = 1 to 11 using a parallel plate analyser to record photocurrent (J_{ph}) as a function of retarding voltage (U_{ret})



- Activation interrupted periodically to measure the longitudinal energy spread (LEDC), $n_e^{\ i}(\varepsilon_{\text{lon}})$ at positions i = 1 to 11 using a parallel plate analyser to record photocurrent (J_{ph}) as a function of U_{ret}
- ε_{lon} varies according to Q.E.(t), but is constant after measurement #7



• Effective electron affinity, $\chi^* = \varepsilon_{vac} - \varepsilon_{cb}$, calculated for points 1 to 11

- ε_{vac} coincides with the electron energy where $\delta n_e(\varepsilon_{lon})/\delta \varepsilon_{lon}$ is maximum
- $\varepsilon_{cb} = e \cdot U_{ret}$ where $\delta^2 J_{ph}(U_{ret}) / \delta U_{ret}^2$ has its minimum value



Electron affinity reaches its minimum value after 250 minutes.

The data show that the energy diagram for the p-GaAs(Cs,O)-surface remains un-changed for t > 250 min, **as predicted by the HJ model**.



Evolution of the oxygen content (C_{ox}) within the (Cs,O)-layer during activation. The dotted lines are linear extrapolations of the measured (solid) curves.

The data show that the energy diagram for the p-GaAs(Cs,O)-surface remains un-changed for t > 250 min, **as predicted by the HJ model**.



p-GaAs (Cs,O): Activation Layer Model

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p-GaAs(Cs,O)-photocathodes: Demarcation of domains of validity for practical models of the activation layer

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The (Cs,O)-activation procedure for p-GaAs(Cs,O)-photocathodes was studied with the aim of demarcating the domains of validity for the two practical models of the (Cs,O)-activation layer: The dipole layer (DL) model and the heterojunction (HJ) model. To do this, the photocathode was activated far beyond the normal maximum of quantum efficiency, and several photocathode parameters were measured periodically during this process. In doing so, the data obtained enabled us to determine the domains of validity for the DL- and HJ-models, to define more precisely the characteristic parameters of the photocathode within both of these domains and thus to reveal the peculiarities of the influence of the (Cs,O)-layer on the photoelectron escape probability. © 2015 Author(s). All article content, except where otherwise noted, is licensed under a Creative Commons Attribution 3.0 Unported License. [http://dx.doi.org/10.1063/1.4919447]

..... for the full story, download the open access paper.







- Continue to work with the Institute of Semiconductor Physics
 - Repeat the activation layer experiment at Daresbury measuring the *transverse energy spread* with the TESS
- Construction of a vacuum suitcase (nearly complete)
- Building a collaboration with the source group at CERN
- Studies of the energy spread from NEA GaAs photocathodes subjected to programmed degradation
- Energy spread measurements from cooled GaAs photocathodes
- Integration of a broadband light source with the TESS system
- Studies of energy spread from metal photocathodes



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Imperial College London



Thank you!

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